

ICS 71.060.20

HG

**CHEMICAL INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

HG/T 4526-2013

Silica for matting

消光用二氧化硅

(English Translation)

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2 Normative references

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HG/T 4526-2013 cites the following standards, which apply in full or in part through the references made to them in its clauses.

GB/T 191-2008

GB/T 3049-2006

GB/T 6678

GB/T 6682-2008

GB/T 8170

GB/T 23774-2009

HG/T 3696.1

HG/T 3696.2

HG/T 3696.3